


Challenges and Implementation of Online In Situ R_{DSON} Measurement in a Three-Phase Inverter

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Abstract—This article addresses the critical issue of real-time monitoring of ON-state resistance (R_{DSON}) of all power semiconductor devices within a three-phase inverter. An optimized ON-state voltage (V_{DSON}) measurement circuit and configuration for a multiphase converter architecture is proposed, designed to overcome the challenges posed by different characteristics and nonidealities of current and voltage sensor components. In addition to the hardware, the solution includes a data processing and qualification strategy that minimizes the impact of switching noise and processing circuitry nonidealities on R_{DSON} calculation. The efficacy of the approach is demonstrated through experimental results from a three-phase inverter, which is designed with silicon carbide metal-oxide-semiconductor field-effect transistors. This work contributes a novel solution to the field, enhancing the reliability and efficiency of power semiconductor device monitoring.

Index Terms—Online in situ health monitoring, ON-state resistance (R_{DSON}).

I. INTRODUCTION

THE widespread adoption of electric vehicles and the increasing integration of renewable energy resources are driving a growing role for power electronics in the electrical grid [1], [2]. This is further amplified by the ever-expanding volume of electronic devices in everyday applications. With such widespread adoption, a measurable subset of power electronic converters will fail in operation, resulting in cascading consequences. Among many components in the power converters, 57.1% of the converter failures are attributable to the power semiconductors [3]. As semiconductor devices are one of the primary causes of converter failures, monitoring the health status of these devices improves the overall reliability of the power converters.

In recent years, research on real-time monitoring of power electronic systems to increase reliability and prevent failure has

become an important topic [4], [5], [6], [7], [8]. The power semiconductor devices (MOSFETs/IGBTs/HEMTs) age through different degradation mechanisms caused by various electro-mechanical stresses in long-term operations [9], [10], [11], [12]. Increase of ON-state resistance (R_{DSON}) results from many degradation mechanisms, such as gate-oxide degradation and bond wire degradation [13]. Therefore, R_{DSON} is a good indicator of device health status and is suitable for in situ prognostics [14], [15], [16], [17]. The power electronics community has attempted to implement in-situ monitoring of R_{DSON} of power transistors, but research has only been reported on a low-side device either in a double pulse test (DPT) setup or in a converter where the low-side device acts as an active switch such as a dc–dc boost converter or a power factor correction (PFC) converter [4], [5], [6], [7], [14], [15], [16]. Independent and simultaneous R_{DSON} measurement of individual transistors is more effective, as a failure of a single transistor may lead to the failure of the entire system. Real-time accurate R_{DSON} value of the MOSFET could be used to evaluate degradation or estimate the remaining useful lifetime [18], [19], [20], [21].

Fan et al. [22] and Mitrovic et al. [23] presented system implementation for real-time condition monitoring of MOSFETs in a three-phase inverter using R_{DSON} measurement. Fan et al. [22] present a concept of online stress index and health index generation with R_{DSON} measurement and Junction temperature estimation. Online stress and health index can be very valuable for a converter for monitoring health and predicting failure. Mitrovic et al. [23] present a concept of an integrated gate driver solution with ON-state voltage (V_{DSON}), current and dc-link voltage measurement. An integrated gate driver with health monitoring feature provides a path for scalable monitoring solutions. While both papers [22] and [23] provide R_{DSON} measurement using V_{DSON} and drain-source current (I_{DS}), there are significant differences in terms of hardware and software implementation and validation methods between our work and the previous works. Fan et al. [22] and Mitrovic et al. [23] use traditional V_{DSON} sensors referenced to the floating points of the half-bridges, making them susceptible to switching noise. Besides, both papers [22] and [23] did not provide detailed explanations on sensor synchronization and switching noise rejection methods. These are critical challenges for the implementation of the real-time in situ measurement to a practical inverter. Lack of synchronization and data qualification leads to increased probability of error in the R_{DSON} calculation specially in a high-frequency converter with high rate of change in current

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TABLE I
TOTAL ISOLATED POWER SUPPLY REQUIREMENT FOR V_{DSON} SENSING

Inverter topology	Traditional V_{DSON} sensing circuit	Proposed V_{DSON} sensing circuit
3 leg, 3-phase	4	2
4 leg, 3-phase	5	2

and voltages. Papers [22] and [23] also lack proper accuracy assessments to validate their measurements, which are provided in our article.

This article presents a complete implementation of online in situ R_{DSON} monitoring of all six power transistors (MOSFETs) used in a practical three-phase DC–AC inverter containing three half-bridge (HB) legs. This article addresses the challenges of the simultaneous R_{DSON} monitoring of all MOSFETs during real-time inverter operations and proposes the implementing solution. This article offers significant improvements in accuracy and noise reduction by both hardware and software improvements. The contributions of this article are as follows.

- 1) A new V_{DSON} sensing circuit allowing a common reference of the analog measurement signals for all high-side MOSFETs—proposed by Roy et al. [24], [25]—is used for the online in situ R_{DSON} measurement, and its effectiveness in this application is validated for the first time. The proposed V_{DSON} sensor board reduces the complexity of power supply circuits and the size of the printed circuit board, so the board can be installed on top of the MOSFET modules seamlessly in the existing inverter hardware. This seamless integration minimizes parasitic loop resistances and impedances between MOSFET devices and the sensing circuit for more accurate R_{DSON} measurement. In addition, the drain referenced V_{DSON} sensors provide a stable reference ground for the measurement circuits making them less susceptible to switching noise. Furthermore, having a common reference for all the high side V_{DSON} sensors, our implementation reduces the total isolated power supply requirement for V_{DSON} sensing as per Table I.
- 2) Data sampling, synchronizing, qualifying, and computing strategies are developed to obtain meaningful R_{DSON} data out of a noisy environment during the inverter operation. The proposed signal processing strategy is essential to minimize the impact of electromagnetic interference (EMI) noises generated by sinusoidal switching operation of six MOSFET devices in a three-phase inverter. Our article presents a comprehensive algorithm for these aspects.
- 3) The proposed R_{DSON} monitoring system is implemented in a 75 kW three-phase inverter containing three silicon carbide (SiC) MOSFET HB modules for experimental validation. Our paper provides a comprehensive accuracy analysis and comparison with commercial measurement equipment which the existing papers lack. The true R_{DSON} of the six devices is measured under a controlled DC condition to compare with the online in situ R_{DSON} under normal AC operating conditions. A comparison of AC

versus DC R_{DSON} and a comprehensive analysis of the effect of parasitic impedance is presented in this article.

The rest of this article is organized as follows. Section II presents the concept of online in situ R_{DSON} monitoring and its implementation challenges. Section III presents the complete system architecture and the V_{DSON} and current sensing circuitry. Section IV presents the proposed algorithm for data acquisition and processing on a digital microcontroller (DSP) that controls the inverter. Section V presents the hardware setup, experiment results, and a comprehensive analysis validating the proposed online in situ R_{DSON} measurement. The conclusion is presented in Section VI.

II. ONLINE IN SITU R_{DSON} MONITORING CHALLENGES AND SOLUTIONS

An online health monitoring system requires two primary components, sensors that obtain required data and a control system that processes the sensor data. The concept of online in situ R_{DSON} monitoring is to extract and record the R_{DSON} during real-time converter operation with sensors and processors within the converter. In the in situ R_{DSON} measurement, V_{DSON} , and I_{DS} measurements of power transistors need to be sent to the control system to calculate the R_{DSON} . However, in a multiphase converter with multiple HB legs, all V_{DSON} measurements of individual power transistors do not have a common V_{DSON} measurement reference with traditional sensor configuration. Therefore, the measured V_{DSON} of different devices cannot be directly tied to the control reference. This issue leads to challenges in implementing the in situ prognostics to practical power electronic converters.

For online R_{DSON} measurement in a high frequency converter very high frequency V_{DSON} and I_{DS} sensors are required. Traditional V_{DSON} sensors as described in [22], [23], [26], [27], and [28] use MOSFET's source terminals as the measurement reference. While this approach works well for low-side MOSFETs, it becomes a significant challenge for high-side devices. The source voltage of high-side MOSFETs fluctuates rapidly between the DC bus voltage and ground, with a very high rate of change (dV/dt). These voltage fluctuations make the measurement circuits susceptible to switching noise introduced through various coupling mechanisms, including capacitive, inductive, and ground loop currents. This article proposes a novel technique to address noise challenges in high-side V_{DSON} sensors by introducing a drain reference [24]. Unlike the HB midpoints, which experience significant voltage fluctuations during switching, the drain terminals of the high-side MOSFETs offer a more stable potential. By connecting the V_{DSON} sensor reference to this stable voltage source, the impact of noise injection into the measurement ground is minimized. This consequently enhances the overall noise immunity of the V_{DSON} sensor, leading to more accurate measurements.

A significant challenge in multiphase inverter design is the need for isolated power supplies for V_{DSON} sensors. Traditional methods require a separate isolated supply for each high-side V_{DSON} sensor, while low-side sensors can often share a single

supply. This approach becomes cumbersome and expensive as the number of inverter phases increases.

Our proposed drain-referenced $V_{\text{DS(on)}}$ sensors for high-side MOSFETs eliminate this complexity. By utilizing the drain voltage as a reference, all high-side $V_{\text{DS(on)}}$ sensors can be powered from a single isolated supply within the proposed circuit. This significantly reduces the number of isolated power supplies required. Regardless of the number of HB legs in the inverter, our approach only necessitates two isolated supplies: one for the low-side $V_{\text{DS(on)}}$ sensors and one for the drain-referenced high-side $V_{\text{DS(on)}}$ sensors.

In contrast, a traditional three-phase inverter with three HB legs would require one isolated supply for low-side sensors and three separate supplies for high-side sensors. Table I compares the number of isolated power supplies needed in both approaches, highlighting the cost advantage offered by our proposed solution.

When multiple switching devices are involved, their sinusoidal switching pattern generates EMI that requires special attention in analog and digital signal processing. The measured signals at different electrical nodes are affected by the EMI generated from all devices, and the measured signals contain unpredictable signal noises. Therefore, the analog data sampling strategy becomes essential to extract meaningful data from analog measurements.

This challenge has been addressed with both hardware and software implementation in this article. Our drain referenced high-side $V_{\text{DS(on)}}$ sensors, significantly improve the noise immunity by providing a steady reference, similar to how the low side $V_{\text{DS(on)}}$ sensors benefit from a stable reference. Furthermore, this article proposes a data synchronization and qualification algorithm that is specifically designed to ensure the accuracy of the $R_{\text{DS(on)}}$ calculation under real-time inverter operation. The main considerations of the synchronization are 1) the placement of the $R_{\text{DS(on)}}$ data points close to the center of the pulsewidth modulation (PWM) signal but not affecting the exiting measurements used for control and/or protection and 2) the compensation of the different voltage and current sensing delays which result in wrong $R_{\text{DS(on)}}$ values. An essential layer of filtering—the data qualification—is then applied to eliminate erroneous data affected by the switching transitions of other devices under high modulation index conditions. This step is crucial for filtering out noise and ensuring the validity of the calculated $R_{\text{DS(on)}}$. Implementation details of these solutions are explained in Section IV.

Another challenge is validation of the experiment results. There are no off-the-shelf $V_{\text{DS(on)}}$ / $R_{\text{DS(on)}}$ sensors readily available to compare the experiment results except with the datasheet provided numbers. The $R_{\text{DS(on)}}$ provided in a standard MOSFET datasheet is a range of large number of MOSFETs. For example, the CAS300M17BM2 [29] datasheet lists 8–10 m Ω $R_{\text{DS(on)}}$ for 300 A current at room temperature. It is important to know the actual $R_{\text{DS(on)}}$ of the device under test (DUT) to validate the in situ measurement circuits. The maximum $R_{\text{DS(on)}}$ is 25% higher than the typical value listed, which is a large number to evaluate the in situ measurement accuracy. Therefore, for an accurate comparison, each of the six MOSFETs used in the

inverter are characterized under controlled preset conditions to have the baseline measurements which has been used later for comparison with the in situ measurements.

III. PROPOSED SOLUTION: SYSTEM INTEGRATION FOR ONLINE IN SITU $R_{\text{DS(on)}}$ MONITORING

A. System Architecture for Online In Situ $R_{\text{DS(on)}}$ Monitoring

Two measurements are required for in situ $R_{\text{DS(on)}}$ measurement of a MOSFET, the $V_{\text{DS(on)}}$, and I_{DS} . The measured signals need to be translated into the control reference to convert into digital data for further processing. The conventional voltage clamping circuit measures the $V_{\text{DS(on)}}$ referenced to the source of the MOSFETs. This method allows for the same measurement reference of the $V_{\text{DS(on)}}$ sensing circuits for the three low-side MOSFETs but does not provide a single measurement reference of the high-side MOSFETs. Therefore, the conventional circuit has been modified to simplify the circuit, and a new circuit is proposed to have a single measurement reference of $V_{\text{DS(on)}}$ sensing circuits for the high-side MOSFETs. The $R_{\text{DS(on)}}$ sensing architecture for the three-phase inverter using this new circuit for the high-side is presented in Fig. 1.

For the $R_{\text{DS(on)}}$ calculation, I_{DS} is required along with the $V_{\text{DS(on)}}$. However, adding a current sensor in the switching loop on the drain or source side adds parasitic inductance, increasing loss and creating higher voltage overshoots and undershoots. Instead of adding the current sensor to the drain or source of the MOSFETs, it is connected to the outputs of the half-bridges, as presented in Fig. 1. The line current is good enough for the steady-state $R_{\text{DS(on)}}$ calculation as the steady-state line current is same as the MOSFET current during the ON-state [28]. A commercial off-the-shelf current sensor [30] is used for the current measurement. Therefore, details of the current sensor are not discussed in this article.

Furthermore, the proposed architecture is minimally invasive to the existing inverter architecture. It requires electrical connections to only three outputs of the three half-bridges and the DC bus. This minimally invasive architecture can be implemented on an existing inverter setup with minimal modifications to the hardware.

B. Proposed $V_{\text{DS(on)}}$ Measurement Circuit

The $V_{\text{DS(on)}}$ sensing circuit solving the common signal reference issue of the high-side transistors has been designed by Roy et al. [24] and is used for the online in-situ $R_{\text{DS(on)}}$ measurement for the first time in this article. The designed sensor is precise, has high voltage blocking capability and a quick dynamic response. Using the proposed $V_{\text{DS(on)}}$ sensor board, all the low-side $V_{\text{DS(on)}}$ sensing circuits share a common reference (DC−), and all the high-side $V_{\text{DS(on)}}$ sensing circuits share another common reference (DC+). Designed high-side $V_{\text{DS(on)}}$ measurement circuit, along with the low-side $V_{\text{DS(on)}}$ measurement circuit, are presented in Fig. 2. Selected nodes in the circuit are marked as nodes 1, 2, 3, and 4.

The first stage blocks the high voltage when the transistor is OFF and measures only the low $V_{\text{DS(on)}}$ when the transistor is

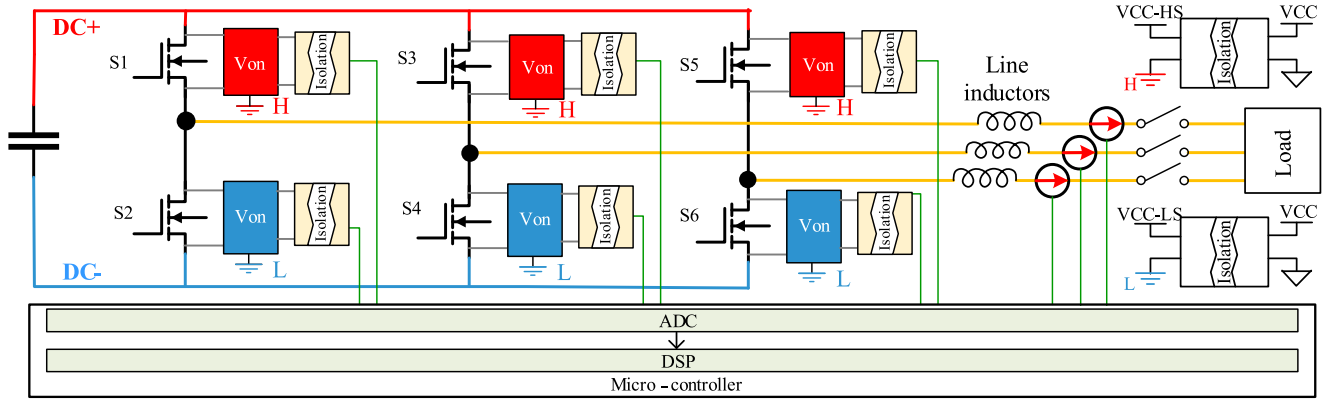


Fig. 1. In situ monitoring architecture implemented on a 3-phase inverter. H and L refers to the high-side and low-side measurement reference, respectively. $VCC-HS$ and $VCC-LS$ are control voltages for the high-side and low-side V_{DSON} measurement circuits respectively.

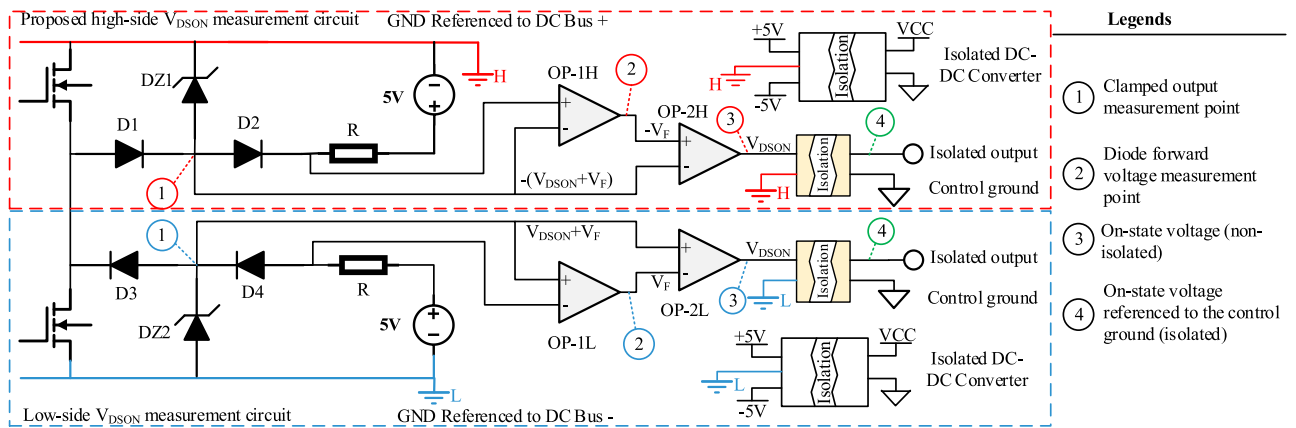


Fig. 2. Proposed circuit for high-side and low-side V_{DSON} measurement. The nodes circled red are referenced to $DC+$, the nodes circled blue are referenced to $DC-$ and the nodes circled green are referenced to the control ground. Same circuit is repeated for the three-phases except the same power supplies are used for all three-phases.

ON. A high voltage (1.2 kV) Schottky blocking diode (D1) [31] is connected to the source of the high-side transistor, which only allows current flow from the source to the V_{DSON} measurement circuit. When the transistor is turned OFF, D1 becomes reverse biased and disconnects the source terminal from the measurement circuit. A Zener diode DZ1 is used between measurement node 1 and the corresponding ground to set the OFF-state voltage at node 1. This ensures node 1 maintaining a specific voltage regardless of fluctuations in the auxiliary power supply voltage. Additionally, the Zener diode provides a freewheeling path for the current within the clamping circuit during the OFF-state. This freewheeling path is crucial because without it, a high voltage overshoot would occur at node 1 when the blocking diode (D1) transitions from forward bias to reverse bias. When the transistor is turned ON, D1 becomes forward biased, completing the circuit through the transistor. During the ON-state, node 1 measures the inverted sum of V_{DSON} and the forward voltage drop (V_F) of D1, which is $-(V_{DSON} + V_F)$. Actual V_{DSON} can be calculated by subtracting V_F from the absolute value of the voltage at node 1. A second Schottky diode (D2), identical to D1, is placed in series very close to D1 so that they operate at a similar temperature level [27]. When the DUT is ON, the same current flows through these two diodes (D1 and D2), ensuring the same forward voltage drop. The voltage drop across the second diode

(D2) is measured using a differential amplifier circuit [32] which is a part of the second stage of the V_{DSON} measurement circuit. The output of this circuit is measured at node 2. The voltage at node 1 is then subtracted from the voltage at node 2, to get the V_{DSON} of the DUT, which is indicated at node 3. Node 4 is the output of the last stage that isolates the measured V_{DSON} from the measurement circuit reference ($DC+$) to the control circuit reference. This is implemented using an off-the-shelf analog isolation amplifier (ADuM4190) [33].

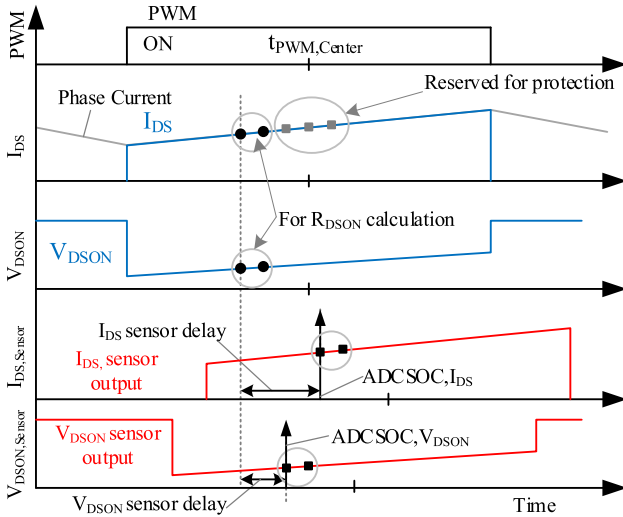
The low-side V_{DSON} measurement circuit works in a similar way, except it references the negative DC bus ($DC-$). The voltages at different measurement nodes depending on the status of the particular MOSFET are summarized in Table II. Further details of the sensing circuit such as design details and output performance are presented in [24].

IV. PROPOSED SOLUTION: ONLINE IN SITU R_{DSON} CALCULATION AND REPORTING

The V_{DSON} and I_{DS} sensor outputs are sampled and processed through a DSP for the real-time R_{DSON} update feature. The sampled data go through a series of data qualification stages to achieve accurate and meaningful measurements.

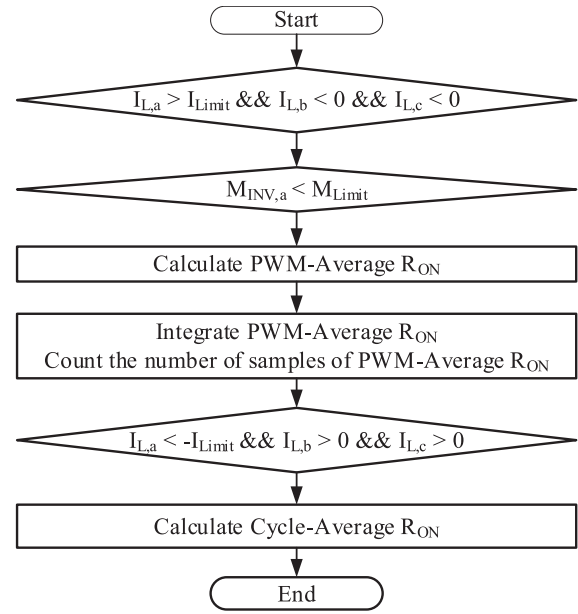
TABLE II
 V_{DSON} CIRCUIT OPERATION AND MEASUREMENTS AT DIFFERENT NODES

Node	MOSFET status	High-side	Low-side
1	ON	$-(V_{\text{DSON}} + V_F)$	$V_{\text{DSON}} + V_F$
	OFF	-3 V	3 V
2	X	$-V_F$	V_F
3	ON	V_{DSON} $=V_{\text{NODE2}} - V_{\text{NODE1}}$	V_{DSON} $=V_{\text{NODE2}} - V_{\text{NODE1}}$
	OFF	$3 - V_F$ $=V_{\text{NODE2}} - V_{\text{NODE1}}$	$3 - V_F$ $=V_{\text{NODE2}} - V_{\text{NODE1}}$


 Fig. 3. V_{DSON} and I_{DS} sampling synchronization for instantaneous $R_{\text{DS(on)}}$ calculation. Blue lines indicate the ideal current and voltage waveforms, and the red lines represent the measured signals. The measurement delay is characterized to align the current and voltage measurements.

A. Data Sampling and Synchronization for Online $R_{\text{DS(on)}}$ Calculation

The first step is reading the V_{DSON} and I_{DS} sensor outputs using the analog-to-digital converter (ADC) module in a DSP. Synchronization of ADC sampling with the PWM signal is one of the important implementation considerations. As shown in Fig. 3, the effective V_{DSON} and I_{DS} waveforms (blue lines) appear when the device is on. Hence, the ADC sampling needs to be completed within this short period. In particular, the center of the PWM on time ($t_{\text{PWM,Center}}$) is the preferred area for accurate ADC sampling by avoiding the potential signal noise near the PWM switching transitions. In fact, three AC inductor currents (I_{La} , I_{Lb} , I_{Lc}) used for the primary inverter functions such as closed-loop control and protection are already sampled at $t_{\text{PWM,Center}}$. Two additional samples of each V_{DSON} and I_{DS} for the online $R_{\text{DS(on)}}$ calculation are captured in advance to the three AC inductor current measurements so that the implementation of the $R_{\text{DS(on)}}$ measurement does not affect the performance of the existing primary inverter functions. These V_{DSON} and I_{DS} measurements are captured before the three AC inductor current samples, as shown in Fig. 3. ADC start-of-conversion (SOC) triggers, $\text{ADCSOC}, I_{\text{DS}}$ and $\text{ADCSOC}, V_{\text{DSON}}$, are programmed to start sampling V_{DSON} and I_{DS} . The V_{DSON} and I_{DS} sensing


 Fig. 4. Developed flowchart for $R_{\text{DS(on)}}$ calculation: Example is shown only for one device, the phase A high-side MOSFET. This is repeated sequentially to get $R_{\text{DS(on)}}$ of all six MOSFETs in one AC-cycle.

circuits have different signal output delays, as shown in Fig. 3 (red lines). These delays are characterized through experiments and presented in the next section. To compensate for these sensing delays, the two ADCSOC triggers are shifted independently to synchronize the V_{DSON} and I_{DS} measurements. As the ADCSOC trigger sources, two unused ePWM channels of the DSP are used, and their event trigger timings are adjusted to apply the different sensor output delays to the ADC sampling as illustrated as the vertical arrows in the fourth and fifth rows in Fig. 3.

B. Data Qualification to Filter Noisy Data From Calculation

Due to practical issues of hardware circuit components, false or noisy sensing output signals may inadvertently be applied to the microcontroller. The first challenge is that the isolated analog amplifier, ADuM4190 [33], has a lower common-mode input range, which does not provide accurate isolated output for inputs that is less than 200 mV. To address this limitation, $R_{\text{DS(on)}}$ is only calculated above 30 A phase current of the inverter. 30 A phase current corresponds to 210 mV voltage drop across the drain and source terminal of the MOSFET considering 7 m Ω $R_{\text{DS(on)}}$. In addition, switching transitions of other phases cause EMI noise on the V_{DSON} and I_{DS} sensing signals, even though the ADC readings are synchronized near the $t_{\text{PWM,Center}}$. It is confirmed that a switching event when the modulation index (of the phase being sampled) is less than 0.85 provides enough time to avoid the switching noise interference from other phases and have noise-free ADC samples. Therefore, the effective range of the modulation index for the $R_{\text{DS(on)}}$ measurement is limited to less than 0.85. The data qualification flow chart is shown in Fig. 4.

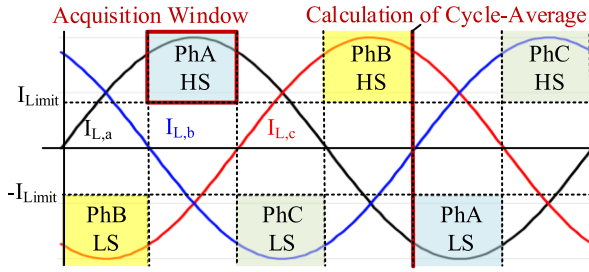


Fig. 5. Three-phase current and voltage sampling window. Shaded areas indicate the current and voltage data acquisition window for the six MOSFETs. Average is calculated in the beginning of the data acquisition of the complementary device of the same leg.

TABLE III
SPECIFICATION OF THE 3-PHASE INVERTER

Parameter	Value
Maximum rated power	75 kW
Nominal input voltage	1000 VDC
Output voltage	480 VAC
Switching frequency	30 kHz
SiC module	CAS300M17BM2

C. Average R_{DSON} Calculation and Reporting

When calculating R_{DSON} , multiple samples of R_{DSON} values are averaged to minimize random fluctuations of the measured data. The PWM-average R_{DSON} is calculated by averaging two samples of R_{DSON} data obtained within a single PWM cycle. The PWM-average R_{DSON} values are integrated during the acquisition window shown in Fig. 5, and the R_{DSON} sum is divided by the number of PWM cycles counted during the acquisition window. The resulted value of this averaging process is called cycle-average R_{DSON} . The cycle-average R_{DSON} is obtained at the beginning of the acquisition window of the opposite device in the same phase leg. This calculation timing is designed to cope with the variation in the width of the acquisition window, which varies according to the inverter's operating condition. All six cycle average R_{DSON} data are updated every fundamental frequency cycle.

V. HARDWARE SETUP AND EXPERIMENT RESULTS

The in situ R_{DSON} monitoring is implemented on a 75 kW three-phase inverter. The specification of the inverter is presented in Table III. The inverter consists of different boards assembled together, as per the cross section shown in Fig. 6. The V_{DSON} sensing board is mounted directly on top of the SiC HB modules. The line current sensors are mounted around the bushing terminals of the output terminals of the inverter. The motherboard has a TI DSP F28379D controlCARD for inverter control and R_{DSON} calculation. Fig. 7 presents a photograph of the developed inverter, which includes the power stage and additional auxiliary components.

R_{DSON} is calculated in three different experiments, 1) DPT; 2) DC condition; and 3) sinusoidal inverter operation.

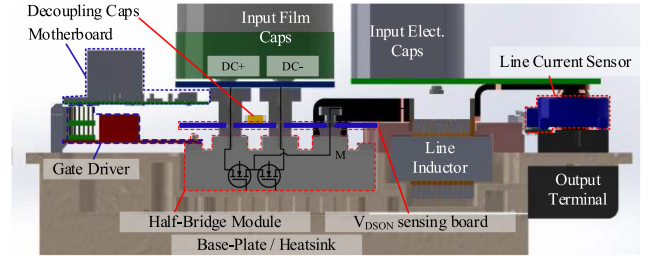


Fig. 6. Cross section of the inverter power stage.

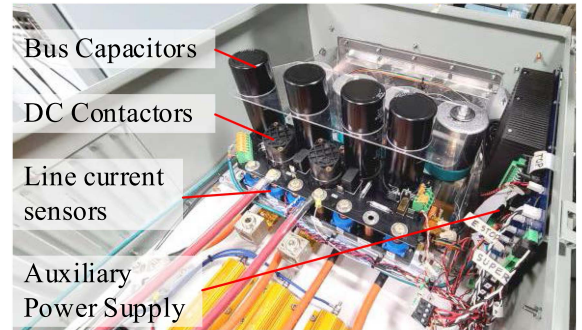


Fig. 7. Developed inverter assembly, includes the power stage, auxiliary power unit, precharge circuitry, contactors, and cooling fans.

A. Sensor Dynamic Characterization in DPT

To find the V_{DSON} and I_{DS} sensor output dynamic characteristics, a DPT is conducted. It has been found that the analog isolator adds $1.2 \mu s$ time delay in the measured signal of the V_{DSON} sensor. Similarly, the hall effect current sensor adds $3 \mu s$ delay to the measured signal compared to the actual current. The current sensor measurement is compared with a Tektronix current probe (TCP0150), having less than 40 ns delays. Fig. 8 presents the delays of the V_{DSON} and I_{DS} sensor outputs. These delays are compensated for, later, during analog data sampling for the R_{DSON} calculation.

B. True R_{DSON} Reference Generation Under DC

The actual DC R_{DSON} of the three modules used in the inverter is measured using precision digital multimeters (DMMs). It is a necessary process to obtain the true R_{DSON} data of the specific SiC MOSFET devices we used to validate the online in situ R_{DSON} measurement results.

The circuit diagram of the experiment setup and the measured R_{DSON} are presented in Fig. 9. A current source is connected to the DUT with a series-connected precision shunt resistor. The voltage across the DUT and the shunt are measured using DMMs. Then the R_{DSON} is calculated using the DMM measurements. The R_{DSON} of the six MOSFETs at 40 A current is listed in Table IV. The R_{DSON} of the six MOSFETs are 6.6, 6.4, 5.9, 5.8, 6.4, and 6.4 $m\Omega$ for S1, S2, S3, S4, S5, and S6, respectively, at 40 A current, which is the selected current for the AC operation.

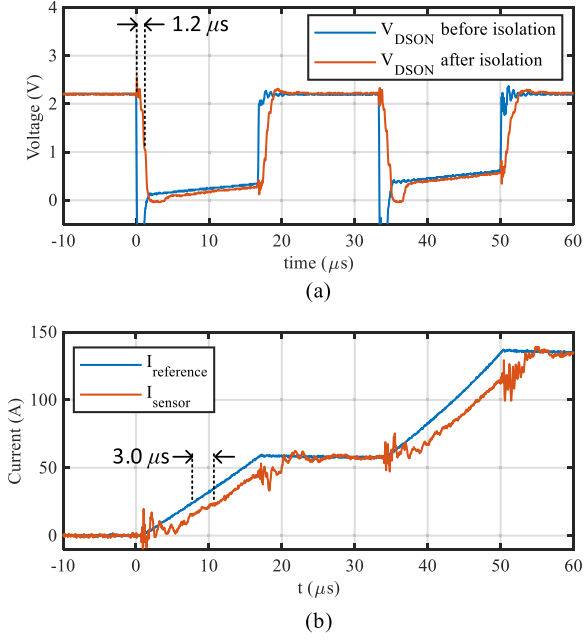


Fig. 8. Experimental evaluation of the voltage and current sensing delays. Isolated V_{DSON} sensor output and current sensor output have 1.2 and 3.0 μs delay, respectively. (a) V_{DSON} sensing delay, and (b) Current sensing delay.

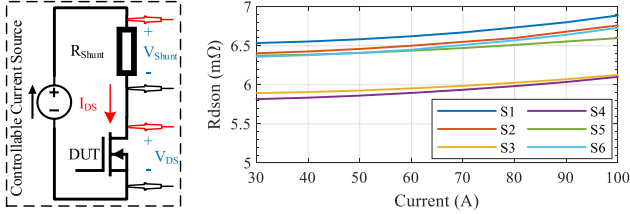


Fig. 9. True R_{DSON} measurement for reference point generation: True (DC) R_{DSON} of the three SiC modules used in the inverter using DMM. Schematic of the test setup (left) and the results (right). The true R_{DSON} data is used to compare with the online measurements.

TABLE IV
TRUE (DC) R_{DSON} OF THE SIX MOSFETS AT 40 A CURRENT
(EXPERIMENTAL RESULTS FOR REFERENCE POINTS GENERATION)

Device	S1	S2	S3	S4	S5	S6
$R_{DSON}(\text{m}\Omega)$	6.6	6.4	5.9	5.8	6.4	6.4

C. Online In Situ R_{DSON} Measurement in Sinusoidal Inverter Operation

For regular inverter operation, all six MOSFETS turn ON and OFF simultaneously following the sinusoidal PWM to generate sinusoidal three-phase output. Fig. 10(a) presents the oscilloscope capture of the V_{DSON} and phase current waveforms in phase-A. The V_{DSON} of the high-side MOSFET is proportional to the positive half cycle of the phase current, and the V_{DSON} of the low-side MOSFET is proportional to the negative half cycle of the phase current. Fig. 10(b) presents the sampled V_{DSON} and I_{DS} data points of the Phase-A high-side MOSFET per every switching cycle during the half cycle of the AC output. These

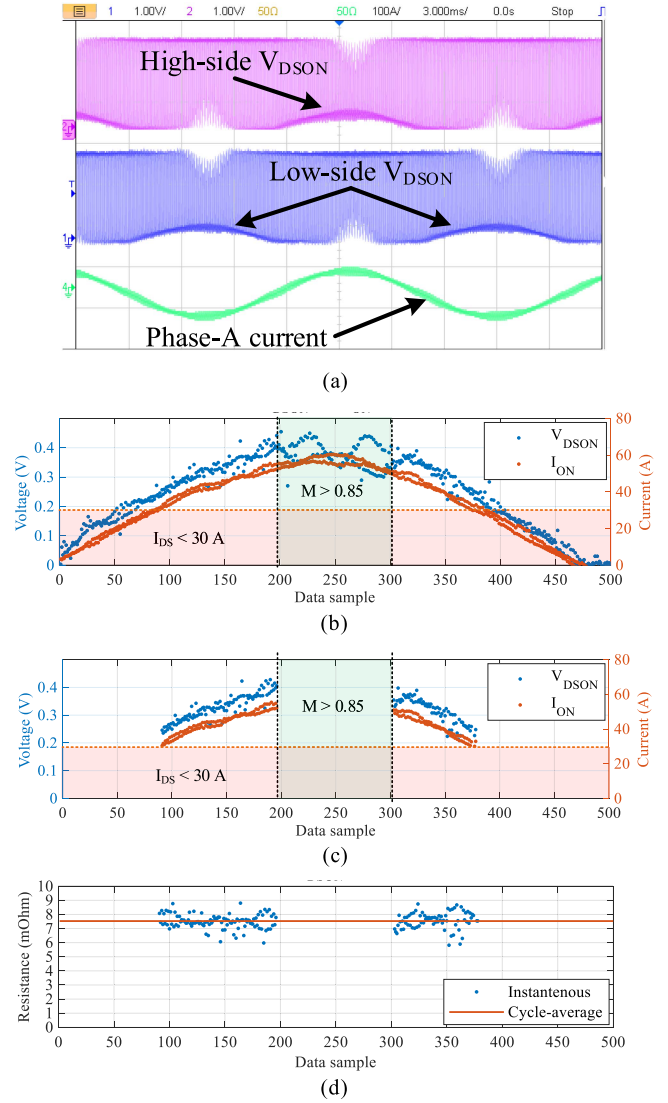


Fig. 10. Experimental results under 1000 V DC–480V AC: Phase A V_{DSON} measurement experimental results for half grid cycle. (a) Oscilloscope capture, (b) sampled V_{DSON} and I_{DS} in the DSP, (c) samples after the data qualifications, and (d) calculated instantaneous and average R_{DSON} .

data points are recorded on the DSP memory and extracted for validation. At the center of the half cycle, where the modulation index is higher than 0.85, the switching noise interferences are observed and are discarded as per the data qualification algorithm. Fig. 10(c) shows data points after the data qualification. After that, PWM-average and cycle-average R_{DSON} values are calculated, as shown in Fig. 10(d). These results verify the feasibility and the effectiveness of the proposed in situ R_{DSON} measurement system architecture and data processing.

For online health monitoring, the cycle averaged R_{DSON} data are recorded and saved. As R_{DSON} is expected to change slowly over a long operating lifetime, the cycle-average R_{DSON} is further averaged every second to reduce the memory requirement to store and process a large number of R_{DSON} data. Fig. 11 presents recorded averaged R_{DSON} for 300 s. The averages of these 300 s data points are 7.5, 6.8, 6.4, 6.0, 6.9, and 6.9 $\text{m}\Omega$ for S1, S2, S3,

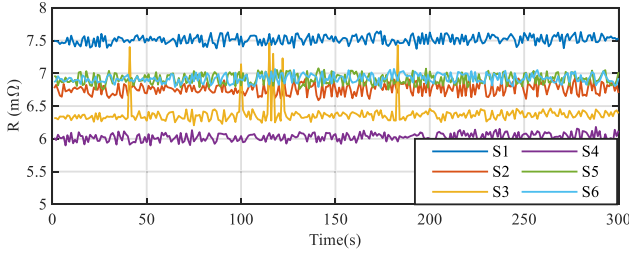


Fig. 11. Experimental results: In situ $R_{DS(on)}$ measurement over 300 s (averaged every 1 s) under 1000 V DC–480 V AC at 30 kW.

TABLE V
ONLINE AC $R_{DS(on)}$ OF THE SIX MOSFETS AND TRUE (DC) $R_{DS(on)}$ UNDER SAME OPERATING CONDITIONS

Device No	S1	S2	S3	S4	S5	S6
True (DC) $R_{DS(on)}$ @40A (mΩ)	6.6	6.4	5.9	5.8	6.4	6.4
AC-Online In-situ $R_{DS(on)}$ @40A (mΩ)	7.5	6.8	6.4	6.0	6.9	6.9
Difference btw DC and Online $R_{DS(on)}$ @40A (mΩ)	0.9	0.4	0.5	0.2	0.5	0.5

S4, S5, and S6, respectively. The $R_{DS(on)}$ of S3 has some random spikes up to 1 mΩ above the average value. A possible reason for the spikes could be noise source along the propagation path of the $V_{DS(on)}/I_{DS}$ sensing signal for this MOSFET. Regardless of the spikes, the data are consistent most of the time. Comprehensive analysis of the measured online $R_{DS(on)}$ is presented in the next section.

D. AC Impedance Analysis

To find the efficacy of the proposed online in situ $R_{DS(on)}$ monitoring architecture the true $R_{DS(on)}$ of each of the six MOSFETs have been characterized under DC conditions to find the baseline $R_{DS(on)}$. The details of the DC characterization test are presented in Section V-B. These $R_{DS(on)}$ references are the true $R_{DS(on)}$ of the six MOSFETs as these were measured using precision digital multimeters in a controlled condition.

The true (DC) and online in situ $R_{DS(on)}$ values at 40 A current are picked from Figs. 9 and 11 and listed in Table V. The online in situ impedances at 40 A current are measured between 6 and 7.5 mΩ. The average online $R_{DS(on)}$ of the six MOSFETs at 40 A is found to be 6.8 mΩ, where the average dc $R_{DS(on)}$ at the same condition from Fig. 9 is 6.3 mΩ. In average, the online $R_{DS(on)}$ is 0.5 mΩ higher than the DC measurements. This deviation between the DC and online measurement should not be considered as a measurement error but effect of the parasitic impedances during AC operation. The online measurement includes parasitic elements that increase the impedance as frequency increases. The impedance seen from the sensor connection point is presented in Fig. 12. Therefore, the measured impedance can be expressed as follows:

$$Z_{Meas} = R_{DS} \parallel \left(\frac{1}{j\omega C_O} \right) + j\omega L_{stray} + R_{contact} \quad (1)$$

where Z_{Meas} is the measured impedance, $1/j\omega C_O$ is impedance due to the output capacitance of the DUT, $j\omega L_{stray}$ is the

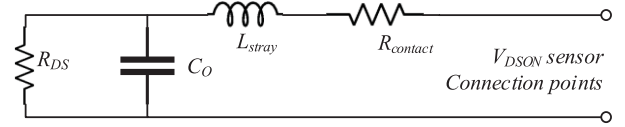


Fig. 12. Representation of the electrical parasitic elements between the MOSFET and $V_{DS(on)}$ sensor interconnection.

impedance due to the stray inductance, and $R_{contact}$ is the contact resistance between the $V_{DS(on)}$ sensor board and HB module, and ω is the frequency of operation. The typical values C_O and L_{stray} are given as 2.9 nF and 15 nH for the SiC module (CAS300M17BM2) tested [29]. As an example, if the resistance for DC $R_{DS(on)}$ is 6.2 mΩ and the contact resistance is 0.1 mΩ, these values will produce an impedance of

$$Z_{Meas} = 0.0062 \parallel \left(\frac{1}{j\omega \times 2.9 \times 10^{-9}} \right) + j\omega \times 15 \times 10^{-9} + 0.0001 \quad (2)$$

which results in $Z = 6.905$ mΩ at 30 kHz, and $Z = 6.3$ mΩ at DC. Therefore, an increase of 0.605 mΩ $R_{DS(on)}$ is expected under AC condition running at 30 kHz compared to the DC measurements. This increase in the magnitude of impedance, 0.605 mΩ in this theoretical example based on the datasheet, is in the same range as the measured 0.5 mΩ average increase of the online in situ $R_{DS(on)}$ under sinusoidal AC condition compared to the true (DC) $R_{DS(on)}$. The difference between the DC $R_{DS(on)}$ and the in situ $R_{DS(on)}$ for the six MOSFETs is presented in Table IV.

VI. CONCLUSION

A complete architecture for an online in situ $R_{DS(on)}$ monitoring has been presented in this article. Various design challenges, such as propagation delays, switching noises, and the operating range of isolators, have been meticulously addressed. A new $V_{DS(on)}$ sensing circuitry, developed with a focus on reducing component count, has been innovatively designed to effectively capture the on-state voltages of high-side and low-side switches of a practical inverter. A software algorithm has been proposed and implemented that collects real-time $V_{DS(on)}$ and I_{DS} data, filters useful data, calculates and reports the in situ $R_{DS(on)}$ of the power MOSFETs. Real-time $R_{DS(on)}$ of the six MOSFETs under 1000 VDC to 480 VAC sinusoidal operation at 30 kW power have been presented in this article demonstrating the effectiveness of our approach. It was observed that the online in situ AC $R_{DS(on)}$ of the six MOSFETs ranges 6.0 to 7.5 mΩ which is on average 0.5 mΩ higher than the DC (true) $R_{DS(on)}$. This increase is attributed to the parasitic impedances that only affect the AC measurements. A comprehensive AC impedance analysis has been presented that supports these observations. The insights gained from this study can be instrumental in assessing the degradation and predicting the remaining useful lifetime of the inverter. While our findings are promising, it is acknowledged that further research is needed to refine our approach and expand

its applicability. This work marks a significant step forward in the field of online health monitoring of power electronics and opens up new avenues for future research.

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